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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
09/963,966	09/26/2001	Shuzo Sato	09792909-5189	1554	
33448	7590 01/02/2004		EXAMINER		
ROBERT J	. DEPKE LEWIS T. STEA	TRAN, BINH X			
	& KNIGHT LLC DEARBORN	ART UNIT	PAPER NUMBER		
30TH FLOO		1765			
CHICAGO, IL 60603			DATE MAILED: 01/02/2004		

Please find below and/or attached an Office communication concerning this application or proceeding.

	1. 2	_			45		
		Appli	ication No.	Applicant(s)			
Office Action Summary		09/96	33,966	SATO ET AL.	_		
		Exam	niner	Art Unit			
			X Tran	1765			
Period fo	The MAILING DATE of this commu or Reply	nication appears ol	n the cover sheet w	ith the correspondence address	; <del></del>		
THE - External control	ORTENED STATUTORY PERIOD I MAILING DATE OF THIS COMMUN insions of time may be available under the provision: SIX (6) MONTHS from the mailing date of this come period for reply specified above is less than thirty to period for reply is specified above, the maximum sure to reply within the set or extended period for repreply received by the Office later than three months ed patent term adjustment. See 37 CFR 1.704(b).	MCATION. s of 37 CFR 1.136(a). In munication. 30) days, a reply within th statutory period will apply a y will, by statute, cause th	no event, however, may a e statutory minimum of thi and will expire SIX (6) MOI le application to become A	reply be timely filed rty (30) days will be considered timely. NTHS from the mailing date of this communi BANDONED (35 U.S.C. § 133).	ication.		
1)⊠	Responsive to communication(s) file	ed on <u>14 October</u>	<u>2003</u> .				
2a) <u></u>	This action is <b>FINAL</b> .	2b)⊠ This action	is non-final.				
3)[]	Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.						
Disposit	ion of Claims						
5)□ 6)⊠ 7)⊠	<ul> <li>✓ Claim(s) 1-35 is/are pending in the application.</li> <li>4a) Of the above claim(s) 13-35 is/are withdrawn from consideration.</li> <li>☐ Claim(s) is/are allowed.</li> <li>☑ Claim(s) 1-3 and 7-10 is/are rejected.</li> <li>☑ Claim(s) 4-6,11 and 12 is/are objected to.</li> <li>☑ Claim(s) 1-35 are subject to restriction and/or election requirement.</li> </ul>						
-	ion Papers		·				
10) <u> </u>	The specification is objected to by the drawing(s) filed on is/are Applicant may not request that any objected Replacement drawing sheet(s) including The oath or declaration is objected	e: a) accepted of	g(s) be held in abeya equired if the drawing	nce. See 37 CFR 1.85(a). g(s) is objected to. See 37 CFR 1.1			
_	under 35 U.S.C. §§ 119 and 120			a 4404			
*; 13)	Acknowledgment is made of a clair All b) Some * c) None of:  1. Certified copies of the priority 2. Certified copies of the priority 3. Copies of the certified copies application from the Internation See the attached detailed Office activation and the standard of a claim since a specific reference was included to TCFR 1.78.  Acknowledgment is made of a claim seed	y documents have y documents have sof the priority document on all Bureau (PCT on for a list of the for domestic prioritied in the first sentenguage provisional for domestic prioritions.	been received. been received in Acuments have been Rule 17.2(a)). certified copies not y under 35 U.S.C ence of the specifical application has buty under 35 U.S.C	Application No In received in this National Stage It received. It is \$ 119(e) (to a provisional application or in an Application Data It is provided to the provisional application or in an Application Data It is provided to the pr	lication) Sheet.		
Attachmen	nt(s)						
2) Notice	ce of References Cited (PTO-892) ce of Draftsperson's Patent Drawing Review ( mation Disclosure Statement(s) (PTO-1449)			Summary (PTO-413) Paper No(s) Informal Patent Application (PTO-152)			

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### **DETAILED ACTION**

### Election/Restrictions

- 1. Applicant's election of Group I (claims 1-12) in Paper filed on 10-14-2003 is acknowledged. Because applicant did not distinctly and specifically point out the supposed errors in the restriction requirement, the election has been treated as an election without traverse (MPEP § 818.03(a)).
- Claims 13-35 are withdrawn from further consideration pursuant to 37 CFR
   1.142(b) as being drawn to a nonelected invention, there being no allowable generic or linking claim. Election was made without traverse in Paper filed on 10-14-2003.

### Specification

3. The lengthy specification has not been checked to the extent necessary to determine the presence of all possible minor errors. Applicant's cooperation is requested in correcting any errors of which applicant may become aware in the specification.

# Claim Rejections - 35 USC § 102

- 4. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:
  - (b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.
- 5. Claims 1-3 are rejected under 35 U.S.C. 102(b) as being anticipated by Watts et al. (US 6,096,652).

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Watts discloses a polishing method of an object having a substrate, an insulating film (310) formed in the substrate, interconnection grooves (300) formed in the insulation film (310) and a conductive layer (330) formed inside and outside of the interconnection grooves. The method comprises the steps of:

supplying a processing solution (a component of medium 345) over the surface to be polished (330) at least substantially parallel to the surface and removing the polishing film (330) formed outside of the interconnection grooves by a shear stress due to the processing solution preferentially from projecting portions of the film to the flatten the surface (Fig 4, col. 4 lines 35-60).

Respect to claim 2, Watts teaches the film (330) comprises a copper film.

Respect to claim 3, Watts discloses the substrate has contact holes (311)

communicating with the interconnection grooves (300) formed in the insulating layer

(310) and having the interconnection layer (330) formed buried inside the contact hole

(311).

6. Claims 7-8 are rejected under 35 U.S.C. 102(b) as being anticipated by Uzoh (US 6,066,030).

Uzoh discloses a method for electropolishing a substrate having the steps of:

supplying an electrolytic solution at least between the substrate surface (3) and a cathode member (5) arranged facing and substantially parallel to the substrate surface while supplying a voltage to the cathode member (5) and the substrate (3) as the anode member and polishing preferentially projecting portions of the substrate by shear stress to the electrolytic solution to flatten the substrate (col. 3-4).

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Respect to claim 8, Uzoh discloses the substrate comprise a copper film (col. 5 lines 15-20).

## Claim Rejections - 35 USC § 103

- 7. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
  - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 8. This application currently names joint inventors. In considering patentability of the claims under 35 U.S.C. 103(a), the examiner presumes that the subject matter of the various claims was commonly owned at the time any inventions covered therein were made absent any evidence to the contrary. Applicant is advised of the obligation under 37 CFR 1.56 to point out the inventor and invention dates of each claim that was not commonly owned at the time a later invention was made in order for the examiner to consider the applicability of 35 U.S.C. 103(c) and potential 35 U.S.C. 102(e), (f) or (g) prior art under 35 U.S.C. 103(a).
- 9. Claims 9-10 are rejected under 35 U.S.C. 103(a) as being unpatentable over Uzoh in view of Watts.

Respect to claim 9, Uzoh fails to explicitly disclose that the substrate has an insulating film formed thereon, interconnection grooves formed on the insulating film, an interconnection layer buried inside the interconnection grooves, and formed over the entire surface outside the interconnection groove. Uzoh also fails to explicitly disclose the step of removing the interconnection layer formed outside the interconnection

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grooves to flatten the surface. However, Uzoh clearly discloses that the substrate has a damascene type structure and the step of removing the interconnection layer (i.e. copper layer) to flatten the surface. Watts discloses the damascene type structure comprises an insulating film (310) formed on the substrate, interconnection grooves (300) formed on the insulating film (310), an interconnection layer (330) buried inside the interconnection grooves, and formed over the entire surface outside the interconnection groove. Watts further disclose the step of removing the interconnection layer formed outside the interconnection grooves to flatten the surface. It would have been obvious to one having ordinary skill in the art, at the time of invention, to modify Uzoh, by having the damascene type structure as discloses by Watts because equivalent and substitution of one for the other would produce an expected result.

Respect to claim 10, Watts discloses the substrate has contact holes (311) communicating with the interconnection grooves (300) formed in the insulating layer (310) and having the interconnection layer (330) formed buried inside the contact hole (311).

### Allowable Subject Matter

- 10. Claims 4-6, 11-12 are objected to as being dependent upon a rejected base claim, but would be allowable if rewritten in independent form including all of the limitations of the base claim and any intervening claims.
- 11. The following is a statement of reasons for the indication of allowable subject matter: The cited prior arts fail to disclose or suggest the step of repeated forming a chelate film on the surface parts of the film exposed at the projecting portions and

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removing by polishing preferentially the projecting portions of the chelate film to flatten the film.

### Conclusion

12. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Binh X Tran whose telephone number is 571-272-1469. The examiner can normally be reached on Monday-Thursday and every other Friday.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Nadine G Norton can be reached on 571-272-1465. The fax phone number for the organization where this application or proceeding is assigned is (703) 872-9310.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is (703) 308-0661.

Binh X. Tran

SJAER VISON NADINE G. NORTON PRIMARY EXAMINER